

IN THE CLAIMS:

1. – 4. (Cancelled)

5. (Currently Amended) A method for manufacturing plasma display panels (PDPs) comprising:

forming a film of MgO on a substrate in an evaporating room, the substrate being held by one of a plurality of substrate holders, the substrate holders comprising a plurality of elements, and

repeatedly using the plurality of substrate holders, such that when the MgO film is formed on a substrate, at least one substrate holder in the evaporating room is coated with MgO film ~~from~~ during forming the MgO film ~~on the~~ a substrate, and at least one holder in the evaporating room comprises elements not coated with said MgO film.

6. (Cancelled)

7. (New) A method for manufacturing plasma display panels (PDPs) in a manufacturing cycle comprising:

forming a film on a substrate in an evaporating room, the substrate being held by one of a plurality of substrate holders, and

repeatedly using the substrate holders for forming film on a substrate, the repeated use comprising a manufacturing cycle,

wherein each time film is formed on a substrate in the manufacturing cycle, other than the first time the film is formed on a substrate, at least one substrate holder in the evaporating room is coated with the film during forming film on a substrate, and at least one holder in the evaporating room is not coated with said film.